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Fax

To:	Examiner Elizabeth Rielley	From:	Robert J. Webster
Fax:	571-273-2117	Date:	August 4, 2006
Phone:		Pages:	4 (including cover sheet)
Your Ref.:	Appl. No.: 10/698,357	Our Ref.:	0630-1861P
Re:	Interview	CC:	

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Comments:

PATENT
0630-1861P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:	Oh-Yong CHOI	Conf. No.:	1165
Appl. No.:	10/698, 357	Group:	2879
Filed:	November 3, 2003	Examiner:	E. Rielley
For:	CATHODE RAY TUBE		

APPLICANT INITIATED INTERVIEW REQUEST

MS AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Examiner's Office Action dated April 7, 2006, Applicant respectfully requests a personal interview to resolve issues presented in that Office Action.

Tentative Participants:

- (1) Examiner Elizabeth Rielley;
- (2) Examiner Mariceli Santiago;
- (3) Mr. Robert J. Webster, Reg. No. 46,472

Proposed Date of Interview Wednesday, August 9, 2006 at 2 P.M..

Type of Interview Requested: Personal

Exhibit(s) to be shown or Demonstrated: None

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Issues to be Discussed:

- (1) Is at least one of the long and short side of Nose's mask frame concaved toward an inside of the mask frame?
- (2) Does Nose disclose a panel of which an outer surface is substantially flat?
- (3) Does Tani disclose that the long and short sides of its mask frame are slanted from ends toward centers to maintain a predetermined interval with the long and short sides of the shadow mask?
- (4) Does the Office Action provide objective factual evidence of proper motivation to modify Nose in view of Tani to make the long and short sides of its mask frame are slanted from ends toward centers to maintain a predetermined interval with the long and short sides of the shadow mask?
- (5) Does Tani disclose that its mask frame side wall edges 40a are slanted or curved to be similar to the curvature of the main surface 31 of its shadow mask?
- (6) Does either Nose or Tani disclose or suggest that the claimed intervals (D_{Lc}, D_{li}, D_{Sc}, D_{si}) are result-effective variables?
- (7) Are the angles disclosed by Tsuneta in col. 5 and shown in Figs. 8-12 angles between the vertical side wall 20 and the bottom flange 22b of Tsuneta's shadow mask frame?

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- (8) Does Bauder disclose that an interval between the shadow mask and the shadow mask frame is equal to or larger than 2.6mm in order to minimize temperature differentials?

Brief Description of Arguments to be Presented:

Applicants will argue that the answer to items (1) - (6) and (8) are in the negative and that the answer to item (7) is in the affirmative.

Prompt and favorable consideration of this Request is respectfully requested.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By:


James T. Eller, Jr

Reg. No.: 39,538

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JTE/RJW:tmh